Search Notes

| Application/Control No. | Applicant(s)/Patent under Reexamination | | | | |
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| 10/634,351 | LIN ET AL. | | | | |
| Examiner | Art Unit | | | | |

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| Class | Subclass | Date | Examiner |
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| 524 | Sez | 11-70-200 | 7v- |
| | S83 | 11-10-200 | |
| 95 | 240 | 11-10-200 | |
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Rip A. Lee